

Inhibitive Effects of *cis*-2,6-Diphenyl-3-alkyl Piperidine at Aluminium/1 N Hydrochloric Acid Interface

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Three piperidine molecules *viz.*, *t*-3-methyl-*r*-2,*c*-6-diphenylpiperidine (3MP), *t*-3-ethyl-*r*-2,*c*-6-diphenylpiperidine (3EP), *t*-3,*c*-5-dimethyl-*r*-2,*c*-6-diphenylpiperidine (DMP) were treated in different concentrations to decide their capability to inhibit the dissolution of aluminium in 1 N HCl. Gravimetric method, AC impedance (EIS) and potentiodynamic polarization techniques were employed to ascertain the corrosion of aluminium. The weight loss is found to be concentration and temperature dependent. The effect of temperature (303-333 K) was examined to find out the thermodynamic parameters like ΔH^\ddagger , ΔS^\ddagger and $\Delta G^\circ_{\text{ads}}$ and activation parameter E_a . Polarization data revealed that the piperidine inhibitor molecules were mixed type. By using Nyquist plots the double layer capacitance and charge transfer resistance values were obtained. The impedance data proved the adsorption of inhibitor molecules on the aluminium surface. Surface coverage (θ) parameter was found to fit Temkin adsorption isotherm. Scanning electron microscopy and energy dispersive X-ray spectroscopy (EDS) were utilized to investigate the aluminium surface.

Keywords: EIS, Nyquist plots, Tafel plots, SEM, EDS.

INTRODUCTION

Aluminium and its alloys have low density, corrosion resistance and low cost. The formation of aluminium oxide layer naturally on its surface is responsible for corrosion resistance of aluminium and its alloys. Acids are normally employed for industrial cleaning. However, in HCl and H₂SO₄ the oxide film is susceptible to corrosion [1,2]. For arresting the corrosion in acidic medium, organic inhibitor molecules possessing atoms like N, O, S and P play a crucial role in industries [3,4]. Adsorption of piperidine inhibitor molecules on the aluminium surface is the foremost mechanism of action in its inhibitive role. The method of adsorption of inhibitor molecules are controlled by the charge, nature on the metal surface and the chemical structure of inhibitors. Generally, the tendency to form a stronger coordination bond by the lone pair of electrons in hetero-atoms with the metal surface decides its inhibition efficiency and hence inhibitive efficiency following the order: O < N < S < P [5]. The objective of the present work is to investigate the inhibitive efficiency of three *cis*-2,6-diphenylpiperidines on the corrosion of aluminium in 1 N HCl.

EXPERIMENTAL

Synthesis of the inhibitors: *cis*-2,6-Diphenylpiperidine-4-ones were reduced by Wolff-Kishner reduction method for the synthesis of *cis*-2,6-diphenylpiperidines [6-9] and their structures are depicted in Fig. 1.

Hydrochloric acid (AR grade) from Merck and double distilled water were used for the preparation of 1 N HCl solution. The samples were rectangular plates of aluminium alloy measuring 3 cm × 1 cm × 0.1 cm and the composition of the sample is 99 % Al.

Weight loss studies: The wet silicon carbide emery paper of 100, 200, 400, 600 and 800 grades were used to polish the samples to mirror finish. The samples were washed with double distilled water and degreased in trichloroethene. Three rectangular aluminum plates were immersed in 100 mL of uninhibited and inhibited solution of 1 N HCl for 1 h. As described in the literature, the rate of corrosion (mm/Y), inhibition efficiency and surface coverage (θ) were determined from weight loss values of uninhibited and inhibited solution of 1 N HCl. The weight loss and inhibition efficiency were determined at four different temperatures *viz.*, 303, 313, 323 and 333 K.

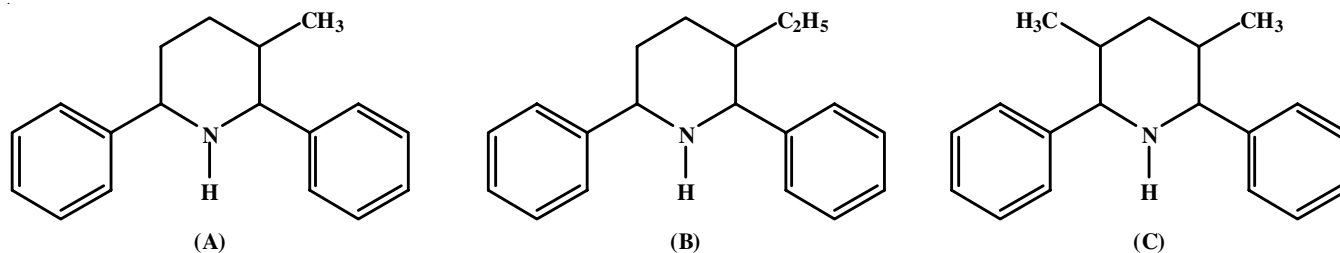


Fig. 1 Chemical structure of piperidines (A) *t*-3-methyl-*r*-2,*c*-6-diphenyl-piperidine (3MP), *t*-3-ethyl-*r*-2,*c*-6-diphenylpiperidine (3EP), *t*-3,*c*-5-dimethyl-*r*-2,*c*-6-diphenylpiperidine (DMP)

Electrochemical analysis: The conventional three cell electrode assembly was used for EIS. The working electrode used was the same aluminium sample implanted in Teflon with an uncovered area of 1 cm². The saturated calomel electrode and platinum electrode were employed as a reference and Auxiliary electrodes, respectively. Potentiodynamic polarization studies and electrochemical impedance measurements were carried out at the open circuit potential using Potentiostat/Galvanostat/FRA2 (μ Autolab type 3) under laboratory air condition. Potentiodynamic polarization curves were measured from +200 mV to -200 mV with a sweep rate of 1 mV s⁻¹ with respect to the corrosion potential. Tafel extrapolation method was employed to determine E_{corr} and I_{corr} values. Before measuring potentiodynamic polarization, electrochemical impedance values were obtained at 30 ± 1 °C and at open circuit potential. Ivium frequency response analyzer with a signal amplitude perturbation of 10 mV was used to get the superimposed sine wave AC signal. Altering the frequency range from 100 KHz to 0.01 Hz, the impedance spectra were measured.

RESULTS AND DISCUSSION

Gravimetric measurements: The weight loss, corrosion rate and inhibition efficiency of *t*-3-methyl-*r*-2,*c*-6-diphenyl-piperidine (3MP), *t*-3-ethyl-*r*-2,*c*-6-diphenylpiperidine (3EP), *t*-3,*c*-5-dimethyl-*r*-2,*c*-6-diphenylpiperidine (DMP) with various concentrations on aluminium surface in 1 N HCl are listed in Table-1. The inhibition efficiency raises with increase in concentration of the inhibitor and reaches a maximum at 5 mM for all the inhibitors. The inhibitor efficiency follows the order 3EP > 3MP > DMP in 1 N HCl. The same trend was proposed by Mahmoud [3] for piperidines on zinc alloy. We have obtained the same order for *N*-formyl piperidin-4-ones [4]. This may be due to the electron releasing nature (+I effect) of alkyl groups. The electron releasing ability raises with increase in chain length of alkyl groups and hence the ethyl group shows more efficiency than methyl group. When inhibitor molecules are present in large numbers it increases the probability of adsorption on the metal surface, leading to the increased inhibition efficiency [10].

Electrochemical impedance: The typical Nyquist plots of aluminium in inhibited and uninhibited acid solution containing a range of concentrations of 3MP, 3EP and DMP are shown in Figs. 2-4. It is evident from Table-2 that the R_{ct} value and inhibition efficiency increases with the raise in the concentrations of piperidine molecules. Diffusion process and activation process are known methods of inhibition by organic molecules. Usually, Nyquist plots obtained for a semi-circular loop for the activation controlled inhibition process and a linear

Inhibitor	Conc. (mM)	HCl		
		Weight loss (g)	Corrosion rate (mm/y) \times 100	IE (%)
	Blank	0.2847	30.79	–
3MP	0.1	0.2483	26.85	12.79
	1.0	0.1832	19.81	35.65
	3.0	0.1433	15.50	49.70
	5.0	0.1394	15.07	51.04
3EP	0.1	0.2419	26.16	15.03
	1.0	0.1784	19.29	37.34
	3.0	0.1405	15.19	50.65
	5.0	0.1302	14.08	54.27
DMP	0.1	0.2513	27.16	11.73
	1.0	0.2182	23.60	23.36
	3.0	0.1939	20.97	31.89
	5.0	0.1785	19.30	37.30

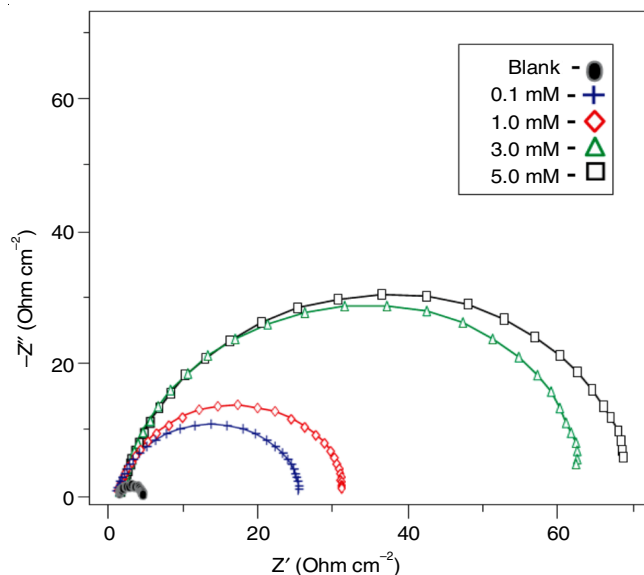


Fig. 2. Nyquist representation for Al in 1 N HCl in the absence and presence of 3MP

pattern for a diffusion controlled inhibition process. Since all the inhibitor molecules shows semi-circular loops in their Nyquist curves, the inhibition by piperidine molecules on aluminium surface is activation controlled.

Fig. 5 shows the Randles equivalent circuit used for the impedance analysis. These circuits fall into the classical parallel resistor capacitor combination, the acid solution dissolved with inhibitor molecule acts as a series resistor.

TABLE-2
ELECTROCHEMICAL DATA OF ALUMINIUM IN 1 N HCl

	Conc. of inhibitor (mM)	R_{ct} (Ohm cm^2)	C_{dl} (F) $\times 10^{-5}$	IE (%)	β_a (mV)	β_c (mV)	I_{corr} ($\mu A/cm^2$)	$-E_{corr}$ (mV)	Corrosion rate (mm/y)	R_p (Ohm)	IE (%)
	Blank	19.6	5.14	–	18	104	982.5	776.9	14.93	8.556	–
3MP	0.1	24.25	6.50	19.18	22	113	743.8	801.9	11.3	11.13	24.30
	1.0	36.41	6.14	36.17	21	108	519.3	800.9	7.892	18.17	47.15
	3.0	51.58	6.05	62.01	17	89	347.9	793	3.96	27.09	64.59
	5.0	62.06	5.13	68.42	20	74	196.2	787.5	2.982	44.09	80.03
3EP	0.1	32.15	5.69	39.04	19	90	619	800.1	8.6	16.65	37.00
	1.0	47.29	4.98	58.55	19	87	427.4	796.1	6.496	18.92	56.5
	3.0	57.6	4.88	65.97	16	85	260.5	794.5	5.297	37.01	73.49
	5.0	65.27	4.63	69.97	15	87	185.2	784.7	2.815	43.42	81.15
DMP	0.1	23.12	8.34	15.22	21	119	846.4	799	14.38	10.67	13.85
	1.0	33.85	7.38	42.10	21	105	673.4	791.3	10.23	14.41	31.46
	3.0	46.18	5.07	57.56	20	102	458.2	789.6	6.964	20.14	53.36
	5.0	60.40	4.58	67.55	17	94	361.5	785	5.494	22.35	63.21

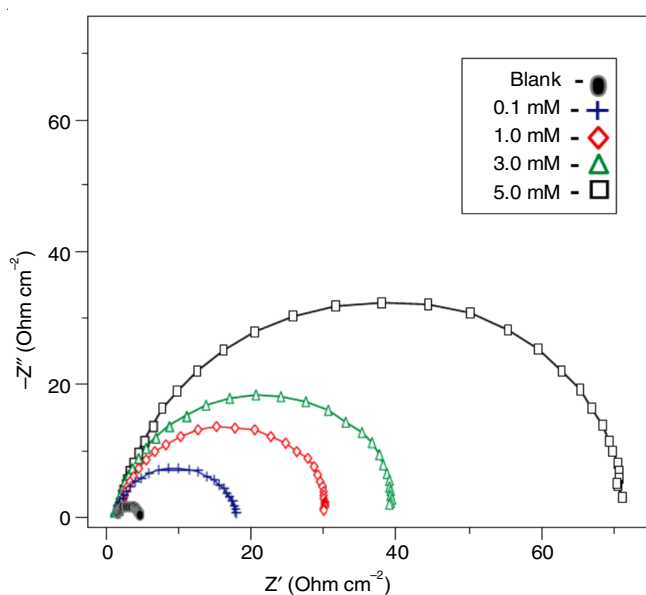


Fig. 3. Nyquist representation for Al in 1 N HCl in the absence and in the presence of 3EP

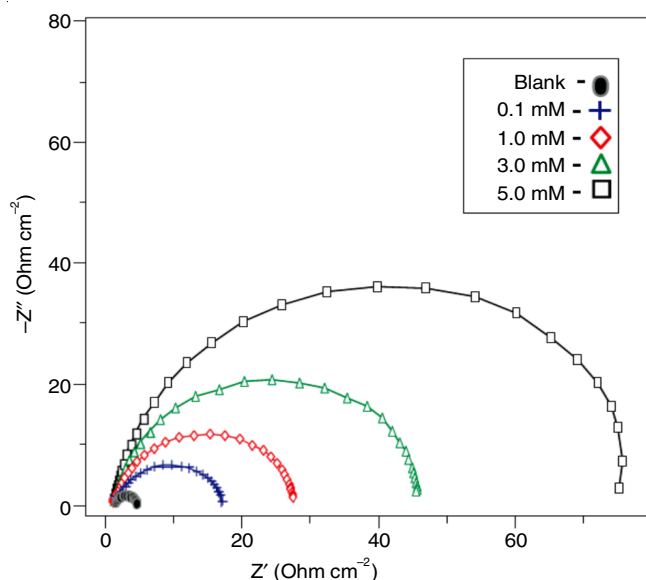


Fig. 4. Nyquist representation for Al in 1 N HCl in the absence and in the presence of DMP

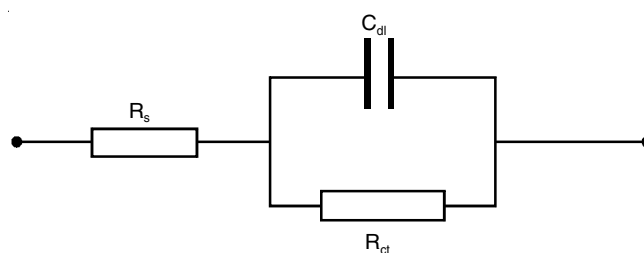


Fig. 5. Randles equivalent circuit

The inhibitor efficiency of all the inhibitor molecules raises with increase in concentration of the inhibitor molecules and which is similar to weight loss method. From the Figs. 2-4, it is suggested that with increase in concentration of piperidine molecules the radius of semi-circle, $R_{ct}/2$ and hence R_{ct} will increase. With progress in adsorption of inhibitor molecule (with low dielectric constant) replaces water molecule on the surface of the metal (with high dielectric constant). This lead to decrease in double layer capacitance C_{dl} . Moreover, with increase in adsorption of the piperidine molecule on the metal surface increases the thickness of the electrical double layer which causes the decreases of C_{dl} values [11,12].

Polarization measurements: The polarization curves for aluminium in 1 N hydrochloric acid solution in the presence and absence of inhibitors are shown in Figs. 6-8. Since the addition of inhibitor molecules to the acid medium alters both the cathodic and anodic Tafel slopes, hence the inhibitors are mixed type. However, the cathodic polarization curves are altered much more than anodic polarization curves and hence they are slightly more cathodic in nature. The corrosion potential (E_{corr}), corrosion current density (I_{corr}), cathodic and anodic slopes (β_c and β_a), the inhibitor efficiency (IE %) are shown in Table-2. The E_{corr} value has a small shift towards the active side with the raises in the inhibitor concentration. Hence, the Al dissolution reaction is controlled, without change in the corrosion mechanism. The blank solution has higher I_{corr} value than the inhibited solution. Adsorption of the piperidine molecules on the metal surface decreases the rate of cathodic hydrogen evolution reaction and anodic metal dissolution.

Effect of temperature: Corrosion rate (CR) and inhibitor efficiency (IE) at 303, 313, 323 and 333 K in presence of 1 mM

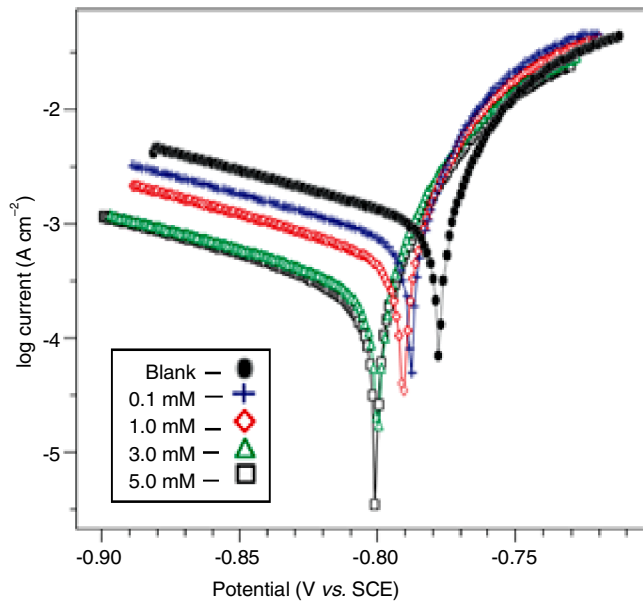


Fig. 6. Tafel polarization curves for Al in 1 N HCl with various concentration of 3MP

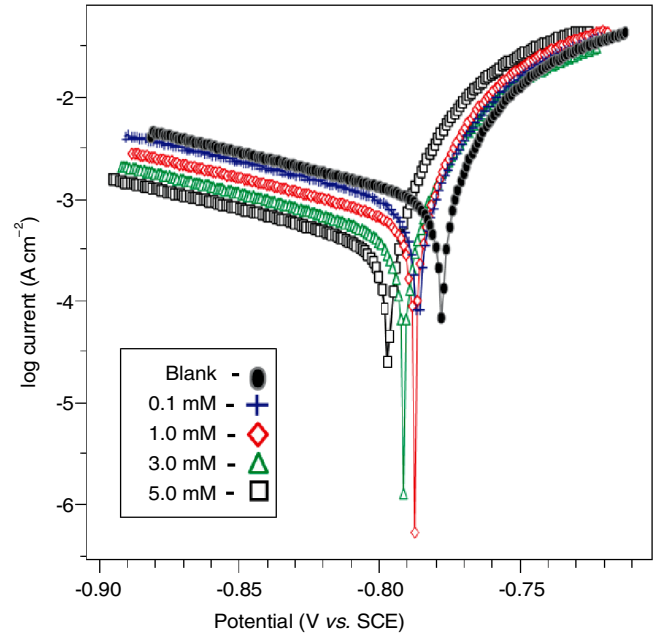


Fig. 8. Tafel polarization curves for Al in 1 N HCl with various concentration of DMP

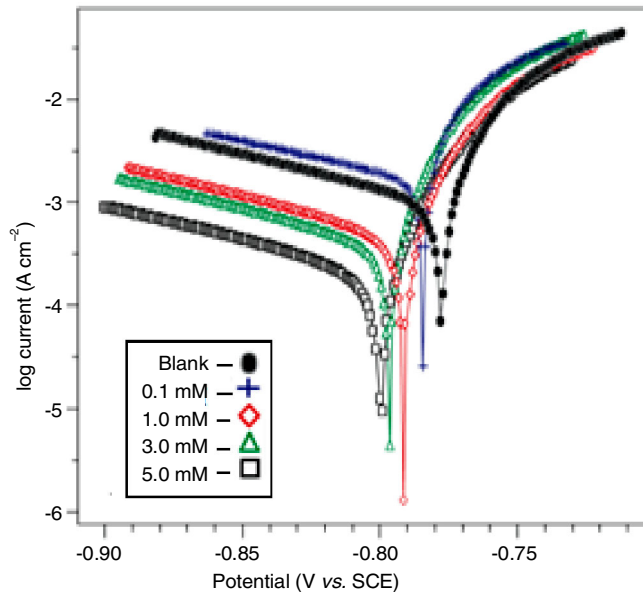


Fig. 7. Tafel polarization curves for Al in 1 N HCl with various concentration of 3EP

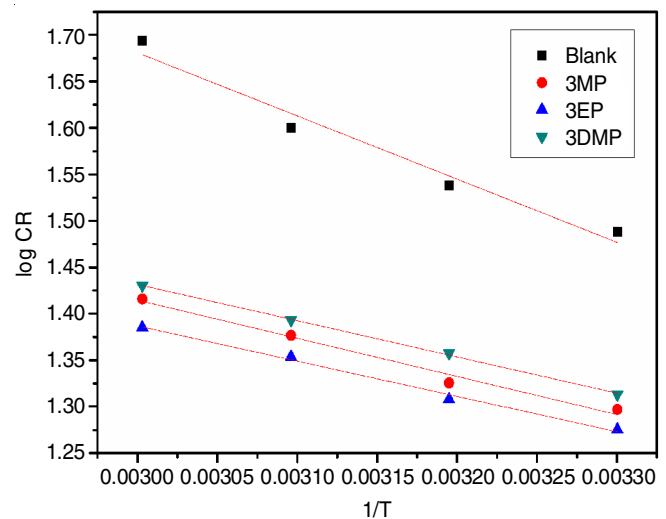


Fig. 9. Arrhenius plot of Al corrosion in 1 N HCl

inhibitors concentration are given in Table-3, which shows that the inhibitor efficiency increases with rise in temperature up to 333 K.

The thermodynamic parameters E_a , ΔH^\ddagger and ΔS^\ddagger are deduced from Arrhenius equation (1) and transition state equation (2). Fig. 9 depicts a plot $\log CR$ versus $1/T$, which give a straight line with a negative slope equal to $E_a/2.303R$. The values of ΔS^\ddagger

and ΔH^\ddagger are calculated by a plot of $\log (CR/T)$ versus $1/T$ with a slope of $(-\Delta H^\ddagger/2.303R)$ and an intercept of $(\log R/Nh + \Delta S^\ddagger/2.303R)$.

$$k = A \exp\left(\frac{-E_a}{RT}\right) \quad (1)$$

$$k = \frac{RT}{Nh} \exp\left(\frac{\Delta S^\ddagger}{R}\right) \exp\left(\frac{-\Delta H^\ddagger}{RT}\right) \quad (2)$$

TABLE-3
EFFECT OF TEMPERATURE ON ALUMINIUM CORROSION INHIBITION IN HCl-MEDIUM

System	303 K		313 K		323 K		333 K	
	CR (mm/y)	IE (%)	CR (mm/y)	IE (%)	CR (mm/y)	IE (%)	CR (mm/y)	IE (%)
Blank	30.79		34.50		39.81		49.37	
3MP	19.81	35.65	21.15	38.68	23.80	40.21	26.04	47.25
3EP	18.85	38.78	20.31	41.13	22.58	43.28	24.29	50.80
DMP	20.57	33.19	22.78	33.95	24.74	37.90	26.93	45.45

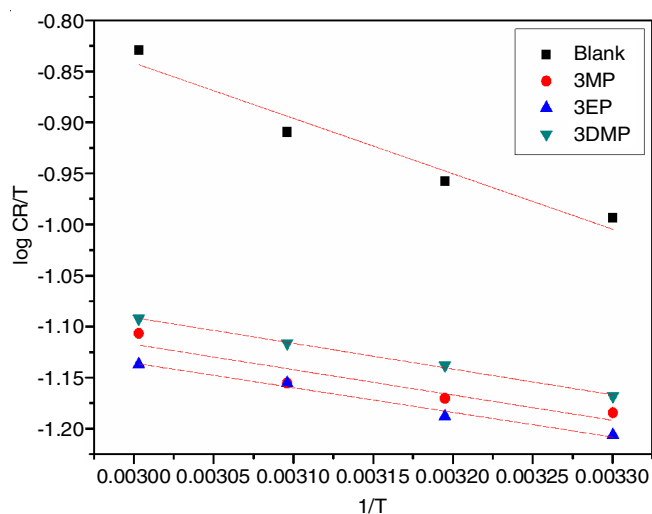


Fig. 10. Kinetic plot of Al corrosion in 1 N HCl

Table-4 indicates that the blank solution has higher activation energy than the inhibited solution. With raise in concentration of the inhibitors, the energy barrier for the corrosion process decreases. The positive sign of ΔH^\ddagger indicates that the exothermic nature of the corrosion inhibition reaction. The entropy of activation (ΔS^\ddagger), in the presence of inhibitor is more negative than the blank, which means that the activated complex in the rate determining step denotes association rather than dissociation.

TABLE-4
THERMODYNAMIC PARAMETERS

Inhibitor	E_a (kJ mol ⁻¹)	ΔH^\ddagger (kJ mol ⁻¹)	ΔS^\ddagger (J K ⁻¹ mol ⁻¹)
Blank	13.024	10.388	-182.52
3MP	7.859	4.747	-204.72
3EP	7.263	4.628	-205.43
DMP	7.471	4.832	-203.96

$\Delta G^\circ_{\text{ads}}$ values are obtained for various temperatures from the expression $\Delta G^\circ_{\text{ads}} = -RT \ln (55.5 \times K)$, (where the equilibrium constant K is equal to $[\theta/(1-\theta) C]$) are presented in Table-5. The strong interaction and spontaneous adsorption of the piperidine molecules on the aluminium surface are confirmed by the negative values of $\Delta G^\circ_{\text{ads}}$ and positive value of ΔH^\ddagger [13,14]. The low values of the ΔH^\ddagger indicate the formation of weak van der Waals bond between the inhibitor molecules and the aluminium surface through electrostatic attraction [15,16].

TABLE-5
GIBBS FREE ENERGY OF ADSORPTION $\Delta G^\circ_{\text{ads}}$ (kJ mol⁻¹)

Inhibitor	303 K	313 K	323 K	333 K
3MP	-8.6329	-9.2557	-9.7235	-10.8183
3EP	-8.9706	-9.5217	-10.0628	-11.2119
DMP	-8.3582	-8.7228	-9.4628	-10.6178

Surface analysis: SEM pictures of virgin aluminium surface in Fig. 11(D,E) specify that the surface of the

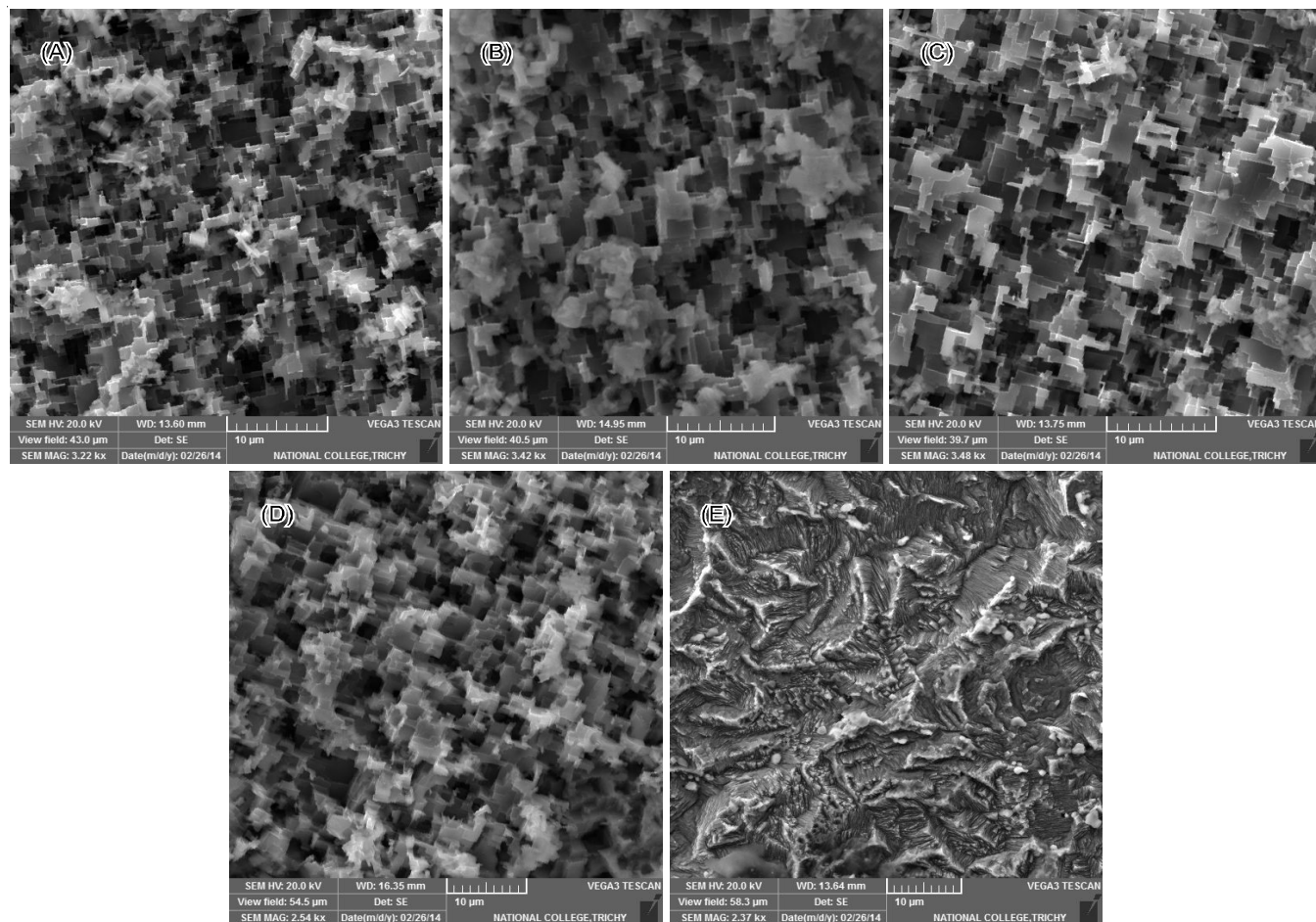


Fig. 11. SEM pictures of uninhibited Al (D and E) and Al surface inhibited by (A) 3MP, (B) 3EP and (C) DMP

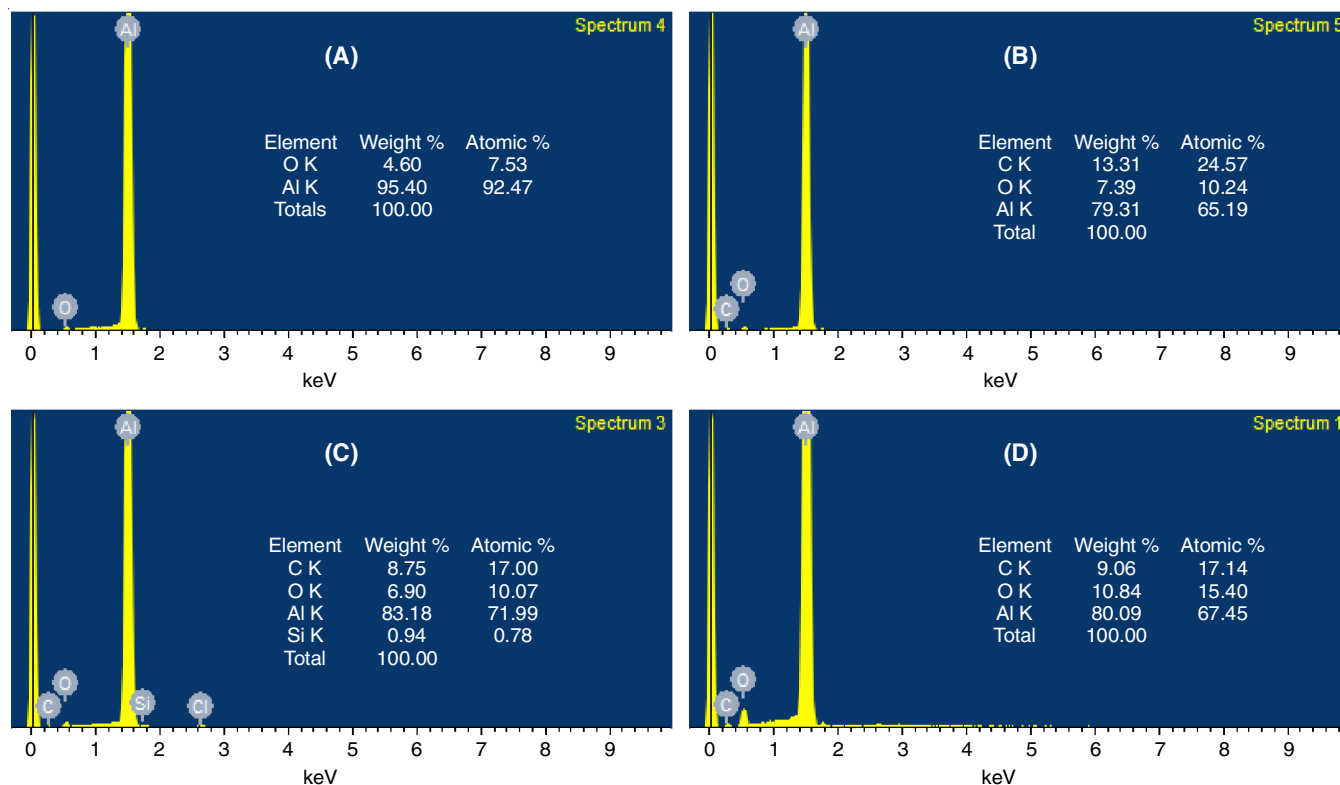


Fig. 12. EDS images of virgin Al surface (A) and Al surface adsorbed by 3MP (B), 3EP (C) and DMP (D)

aluminium is covered with hexagonal type aluminium oxide protective layer with small void surface. These gaps are penetrated by Cl^- ions and the corrosion product molecules are dispersed. The SEM images of inhibited surface in Fig. 11(A,B,C) show that the inhibitors are uniformly adsorbed on the aluminium surface thus exhibiting protective action. By comparing the uninhibited EDS in Fig. 12(A) with inhibited EDS in Fig. 12(B,C,D) it can be derived that the weight percentage of Al has decreased and the weight percentage of carbon has increased, which clearly portrays the adsorption of inhibitors on the metal surface.

Adsorption isotherm: From gravimetric measurements, the degree of surface coverage (θ) for various inhibitor concentrations in 1 N HCl was calculated. The data were tested graphically by fitting the surface coverage values into a suitable adsorption isotherm. Fig. 13 shows that, the adsorption data in this system fits well with Temkin isotherm. This may be due to the formation of mono layer and they form a barrier and thus preventing the metal from reacting with the ions of the aggressive media.

Conclusion

The *cis*-2,6-diphenylpiperidines were found to perform as efficient inhibitors for aluminium surface. The inhibition efficiency increases with the increase in the concentration of the inhibitor molecules. An optimum inhibitor concentration of 5 mM has maximum percentage inhibition efficiency. The inhibition efficiency is affected by raise in temperature and it increases up to 333 K. Polarization data showed that these inhibitors are mixed type inhibitors. EIS studies exposed that when the concentration of the inhibitor is moved up, the IE % and R_{ct} values tend to increase but C_{dl} value decreases. The

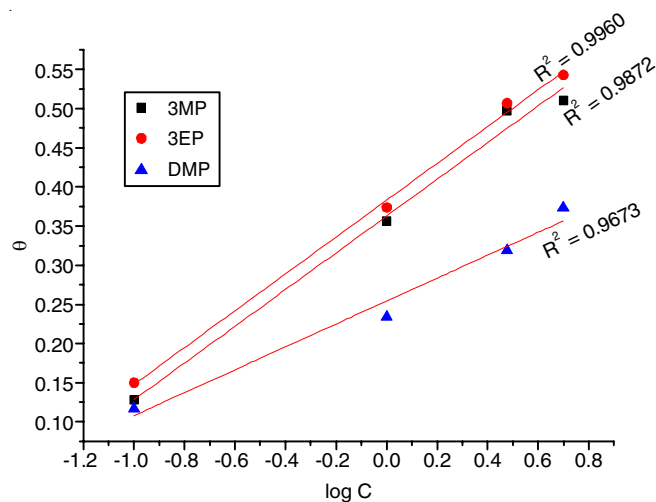


Fig. 13. Temkin Isotherms for the adsorption of inhibitors in 1 N HCl solution

negative values of ΔG_{ads} indicate that the adsorption process is spontaneous. The adsorption of piperidine molecules on the metal surface follows Temkin adsorption isotherms. The low values of ΔH^\ddagger indicate the physical adsorption.

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